

Institute of Applied Physics and Computational Mathematics

# Theoretical investigation of the intrinsic oxygen defects in UO<sub>2</sub> (111) and PuO<sub>2</sub> (111) surfaces

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# **O1** Introduction



## **Photocatalysis**

H. She, et al. ACS Sustainable Chem. Eng. 2018



### Electrocatalysis

J. Chen, et al. J. Energy Chem. 2021





# **Biomedical application**

G. Wang, et al. J. Phys. Chem. C. 2019



### Surface chemistry and corrosion of AnO<sub>2</sub>

G. Wang, et al. J. Phys. Chem. C. 2019

## $AnO_2$ (An = U, Pu)



## Nuclear fuel

### Long-term disposal of the spent fuel

## **Corrosion of uranium**

### **Passive layer**





Layer	UO <sub>2</sub>	PuO <sub>2</sub>	CeO <sub>2</sub>						
<b>1</b> <sup>st</sup>	5.92	3.63	6.45	3.35	5.95	2.49	5.21	2.81	1.84
2 <sup>nd</sup>	5.93	3.93	6.14	3.40	6.08	2.54	4.98	2.43	1.76

T. Bo, et al. J. Phys. Chem. C 2014 J.P.W. Wellington, et al. J. Phys. G. Wang, et al. J. Phys. Chem. C. 2019 J. Paier, et al. Chem. Rev. 2013 Chem. C 2018



Electric charge density

J. Han, et al. J. Mater. Chem. 2011

oxygen diffusivity

A. Kushima, et al. J. Mater. Chem. 2011

#### Vacancy formation

A. Kushima, et al. Phys. Rev. B, 2011

# **O2** Methodology

# Methodology



U: *U* = 4.5 eV, *J* = 0.5 eV

Pu: *U* = 4.75 eV, *J* = 0.75 eV



## $O_{\nu}$ : Oxygen vacancy $O_i$ : Oxygen interstitial

Larger number means deeper depth from the top surface

# Methodology

## Thermodynamics

$$\begin{split} E_{Vo}^{f} &= E_{Slab}^{Vo} - E_{slab}^{ideal} + \mu_{0}(T,p) + qE_{f} \\ E_{Io}^{f} &= E_{slab}^{Io} - E_{slab}^{ideal} - \mu_{0}(T,p) + qE_{f} \\ \mu_{0}(T,p) &= \mu_{0}(T,p_{0}) + (1/2)k_{B}Tln(p/p_{0}) \\ \mu_{0}(T,p_{0}) &= \mu_{0}(0\ K,p_{0}) + (1/2)\Delta G(T,p_{0},O_{2}) \end{split}$$

Т(К)	$\mu_O( extbf{eV})$	Т(К)	$\mu_O( extbf{eV})$
298.15	-0.272	900	-0.974
300	-0.274	1000	-1.010
400	-0.383	1100	-1.227
500	-0.495	1200	-1.356
600	-0.611	1300	-1.486
700	-0.730	1400	-1.618
800	-0.851	1500	-1.751

 $\mu_0(T, p_0) = (\frac{1}{2})[H(T, p_0, O_2) - H(0 K, p_0, O_2)] - (\frac{1}{2})T[S(T, p_0, O_2) - S(0 K, p_0, O_2)]$ 

# Results and discussion

# Formation stability of oxygen defects



#### Formation energies

- O<sub>i</sub> is more easily formed than O<sub>v</sub> in UO<sub>2</sub>, while the possibility of forming O<sub>v</sub> and O<sub>i</sub> is similar in PuO<sub>2</sub>
- O<sub>v</sub> is most likely to form in the second O atomic layer for both UO<sub>2</sub> and PuO<sub>2</sub>
- The formation energy of O<sub>v</sub> gradually tends to be flat. The formation energy of O<sub>i</sub> changes slightly with the surface depth.

# **Electronic properties**



- $\checkmark$  O<sub>v</sub> defect states appear in the band gap of both UO<sub>2</sub> and PuO<sub>2</sub>.
- $\checkmark$  Compared to plutonium, uranium in UO<sub>2</sub> is more prone to bond with additional oxygen atoms

# Strain effect



Variations of formation energy with lattice strain

- Stretching strain promote the formation of O<sub>v</sub>, while compressive strain inhibit O<sub>v</sub>
- Lattice strain has no regular influence on the formation energy of O<sub>i</sub>

# Strain effect



#### **Bond distortion**

- Stretching and compressive strain promote the U(Pu)-O bond distortions for  $O_v$  in UO<sub>2</sub> (111) and PuO<sub>2</sub> (111)
- The variation of the bond distortion induced by lattice strain of Ov in UO<sub>2</sub> (111) changes gently compared with the surface layers

# Thermodynamic phase diagram



- The formation energy of  $O_v$  decreases with temperature, while the formation energy of  $O_i$  increase with temperature.
- The formation energies of  $O_v$  increase with the pressure, while the formation energies of  $O_i$  decrease with increasing pressure
- Stretching strain reduces the formation energy of vacancy, while compressive strain increases it, and formation of Oi is less affected by strain.
- Oi is easier to form in in UO<sub>2</sub> in the considering temperature and pressure range

# Thermodynamic phase diagram



Phase diagram of formation of oxygen defects with different lattice strain

- Low oxygen partial pressure encourages the formation of vacancy, while high oxygen partial pressure facilitates the formation of interstitials
- Stretching strain enlarges the vacancy region and contracts the stable structure phase region, while compressive strain contracts the vacancy phase region and enlarges the stable structure region.

# Conclusions

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#### **Structural stability**

The formation of  $O_i$  is much easier than  $O_v$  in  $UO_2$ , while the formations of  $O_i$  and  $O_v$  have similar chances in  $PuO_2$ .  $O_v$  prefer to form on the subsurface layer for both  $UO_2$  and  $PuO_2$ . Comparatively, the formation of  $O_i$  is insensitive to the incorporation depth.

#### Strain response

Stretching strain reduces the formation energy of vacancy, while compressive strain increases it. Lattice strain has little effect on interstitial oxygen. This strain effect is mainly contributed by the local structural distortion, rather than the electronic hybridization.



#### **Electronic characters**

An  $O_v$  introduces a defect state in the band gap of  $UO_2$  and  $PuO_2$ . For Oi, its electronic states hybridize with neighboring uranium atoms and results in negligible changes in the band structure of  $UO_2$ . Comparatively an  $O_i$  introduces a deep-level defect state in the band gap of  $PuO_2$ .

#### Thermodynamic phase diagram

The strain-modulated formation energy phase diagrams of the oxygen defects have been established over a wide range of temperature and pressure, providing the potential strategy for controlling the type and concentration of intrinsic oxygen defects in  $UO_2$  and  $PuO_2$ 

# Thank you for your listening!